

03560.002732.



PATENT APPLICATION

13/B
5/28/03
D. BEII

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Masato MURAKI et al.

Application No.: 09/708,590

Filed: November 9, 2000

For: CORRECTING METHOD FOR
CORRECTING EXPOSURE DATA USED
FOR A CHARGED PARTICLE BEAM
EXPOSURE SYSTEM

)
: Examiner: K. Fernandez
)
: Group Art Unit: 2881
)
: Allowed: October 28, 2002
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: Confirmation No.: 2106
)
: January 28, 2003
)
:
:

Commissioner for Patents
Box RCE
Washington, D.C. 20231

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JAN 31 2003
TECHNOLOGY CENTER 2800

PRELIMINARY AMENDMENT

Sir:

Prior to further examination on the merits, please amend the above-identified application as follows:

IN THE SPECIFICATION:

Please amend the specification as follows:

Please substitute the paragraph beginning at page 6, line 9, and ending on page 7, line 11, with the following. A marked-up copy of this paragraph, showing the changes made thereto, is attached in Appendix A.